Written by Zone Zero



2011 Tierney Fellowship Centro Fotográfico Manuel Álvarez Bravo

Application Instructions:

The Tierney Fellowship was created in 2003 by The Tierney Family Foundation to support emerging artists in the field of photography. The primary goal of the Fellowship is to find aspiring artists who will be tomorrow's leaders and to assist them in overcoming challenges that photographers face at the start of their careers.

The Fellowship includes the following:

- * \$5,000 cash grant * Mentorship in developing a new body of work over a period of one year
- * Participation in organized critiques and meetings with the Advisory Board and Fellows
- * Posting of final project images on the Tierney Fellowship website
- * Participation in a group exhibition of the final project images
- * Potential exhibition of final project at your institution (dependent on gallery space)

Upon completion of final projects, all Fellows are required to submit a short written report explaining how the program has influenced them as photographers. Each Fellow is also required to provide three final prints, chosen by the Committee, for the archives of the Foundation.

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Application Requirements:

- * Personal Information (name, contact info, etc.)
- * Images (JPG format, max height 700 pixels, max width 1000 pixels)
- * Artist Statement
- * Biography / CV / Resume
- * Statement of Purpose (What will you work on during the project year?)

Applications are only accepted online. In order to apply, please log on to www.tierneyfellowshi and use the

User ID and Password (get it by email:

difusion.cfab@gmail.com

/

cfab_oaxaca@yahoo.com.mx

) under the HOW TO APPLY section where you will create your own personal login.

Login privileges are not transferable. Your submission will be reviewed by the Partner institution you are affiliated with. All submissions not verified by a partner institution will be deleted.

Submit application materials online on or before friday may 27, 2011. No late applications will be accepted.